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ADHESION HYSTERESIS IN MOLECULAR SYSTEMS: UNDERSTANDING THE DISSIPATION PROCESSES AT THE NANOSCALE WITH AFM AND THEORETICAL SIMULATIONS

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DATE / TIME	CHANGED TO: 20.12.2011, 01:30 p.m. (CET)
LOCATION	CHANGED TO: Seminar Room 138B, Vienna University of Technology, "Freihaus"-building, 7th floor, "red area" – Wiedner Hauptstraße 8-10, A-1040 Vienna, AUSTRIA)

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The Scanning Tunneling (STM) and the Atomic Force (AFM) microscopes, due to their high spatial resolution and manipulation capabilities, have greatly contributed to the emergence of Nanoscience and Nanotechnology. The advance has been particularly spectacular in Dynamic AFM, where the development of the frequency modulation operation mode (FM-AFM)[1] has paved the way for atomic-scale imaging [2], manipulation [3] and characterization of the tip-sample forces on all kinds of surfaces, including the chemical identification of individual atoms [4].

In this talk, we discuss how we can combine AFM experiments with the theoretical simulations performed in our group to study the nature of the dissipation processes at the nanoscale. Firstly, we'll introduce the main ideas reviewing our work on semiconductor surfaces with the AFM operated in the frequency modulation mode (FM-AFM), where we have determined the mechanisms for atomic-scale manipulation and identified a common dissipation channel due to single-atom contact adhesion [5,6]. Secondly, we explore, in two technologically relevant organic-based systems, the role of adhesion hysteresis as a dominant dissipation process and the atomistic mechanisms involved. In the case of a monolayer of sexithiophene molecules studied with Amplitude Modulation (AM) AFM, our approach [7-9] includes not only ground-state calculations of the tip-sample interaction, but an extensive set of molecular dynamics simulations at room temperature to include the folding deformation modes that are necessary to describe properly the mechanical response on the molecular layer. Finally, we investigate the origin of the intramolecular contrast in energy dissipation FM-AFM images of PTCDA molecules adsorbed on metal surfaces. Here we illustrate how different deformation mechanisms can contribute to dissipation at different tip-sample distances [10].

[1] S. Morita et al, Noncontact Atomic Force Microscopy, 2nd vol. (Springer-Verlag, Berlin, 2010). | [2] M. Ondracek et al., Phys. Rev. Lett. 106 (2011) 171101 (Editors' Suggestion) | [3] O. Custance, R. Perez and S. Morita, Nature Nanotechnology 4 (2009) 803 | [4] Y. Sugimoto, et al., Nature 446 (2007) 64. | [5] N. Oyabu, et al, Phys. Rev. Lett. 96 (2006) 106101 | [6] Y. Sugimoto, et al, Science 322 (2008) 413 | [7] R. Garcia, R. Magerle and R. Perez, Nature Materials 6 (2007) 405 | [8] N.F. Martinez et al, Nanotechnology 20 (2009) 434021 | [9] W. Kaminski and R. Perez, Tribology Letters 39 (2010) 295 | [10] D.-A. Braun, et al (2011) submitted to Small